

United States Patent and Trademark Office

COMMEDIATE FOR PATENTS AND TRACEMENT OF COMMENTS OF CO

BIBDATASHEET

80b Data Sheet

CONFIRMATION NO. 1185

	<u> </u>					
SERIAL NUMBER 10/080,507	FILING DATE 02/22/2002 RULE	CLASS 430	GROUP AR 1752		ATTORNEY DOCKET NO. 20939B-088710US	
APPLICANTS						
Jae Chang Jung, Ichon-shi, KOREA, REPUBLIC OF:						
Keun Kyu Kong, Ichon-shi, KOREA, REPUBLIC OF; Min Ho Jung, Ichon-shi, KOREA, REPUBLIC OF;Geun Su Lee, Ichon-shi, KOREA, REPUBLIC OF; Ki Ho Baik, Ichon-shi, KOREA, REPUBLIC OF;						
CONTINUING DATA						
This application is a CIP of 09/465,111 12/16/1999 ABN SJL						
FOREIGN APPLICATIONS ************************************						
Foreign Ptiority daimed	D mi O m	STATE OR			·	
as USC 119 (s-d) conditions mai Verified and	Med after	_ COUNTRY	SHEETS	TOTAL	NDEPENDENT	
	inche Segnature Inter	NUKEA	DRAWING 2	CLAIMS 19	CLAIMS 2	
ADDRESS 20350 TOWNSEND AND TOWNSEND AND CREW, LLP TWO EMBARCADERO CENTER EIGHTH FLOOR SAN FRANCISCO, CA 94111-3834						
TITLE Cross-linking monomers for photoresist, and process for preparing photoresist polymers using the same						
	. D All Fees					